

**INFORMATION DISCLOSURE CITATION**  
(Use several sheets if necessary)

Docket Number (Optional)

YOR920010316US1

Application Number

09/893,788

Applicant(s)

Marcos Novaes

Filing Date

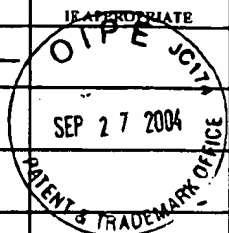
June 29, 2001

Group Art Unit

2171

**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		2003/0005038	01/02/03	Codella et al.			
		6,115,718	09/05/00	Huberman et al.			
		6,272,507 B1	08/07/01	Pirolli et al.			
		6,430,558 B1	08/06/02	Delano			
		2002/0194158	12/19/02	Stensmo			
		6,631,372 B1	10/07/03	Graham			
		6,243,755 B1	06/05/01	Takagi et al.			



**FOREIGN PATENT DOCUMENTS**

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)

<p>EXAMINER</p>	<p>DATE CONSIDERED</p> <p>03/07/2005</p>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		2,923,845	12/13/55	Zunick et al.			
		5,991,796	11/23/99	Anupam et al.			
		5,923,845	07/13/99	Kamiya et al.			
		6,078,948	06/20/00	Podgorny et al.			
		6,233,571	05/15/01	Egger et al.			
		6,629,097	09/30/03	Keith			

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## FOREIGN PATENT DOCUMENTS

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						YES	NO

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